# Inhomogeneous electron distribution in InN nanocolumns

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### Nitride semiconductors:



## GaN, AIN, InN



Bandgap of  $Ga_{1-x}In_xN$  – Solar spectrum High efficiency solar cells.

Wurtzite structure Non-centrosymmetric



### Indium nitride

Low crystalline quality layers. Bandgap ( $E_G$ ): 1.9 eV



10<sup>21</sup>

### Surface electron accumulation layer.



1. Appl. Phys. Lett. **91**, 092101 (2007). 2. J. Appl. Phys. **101**, 081704 (2007). 3. Phys. Rev. Lett. **101**, 106803 (2008).

### Nanocolumns (NCs)



#### Why NCs?

- Higher surface/volume ratio.
- Lower density of dislocations.
- Increase radiative recombination.

NCs grow spontaneously along c-axis. Most surface is non-polar.

Non polar surfaces properties can be studied in more detail.



### InN NCs: samples

-Growth: Plasma-assisted MBE.

- -N<sub>2</sub>-rich conditions
- -Growth time: 300 m.



 $T_{s}$ , Indium beam equivalent pressure (BEP),  $N_2$ -flux: variables.

Sample	Τs	In-BEP	$N_2^{f lux}$	P <sub>RF</sub>
	(±C)	(mbar)	(sccm)	(W)
G053	400	3:0£ 10 <sup>i 8</sup>	2.0	500
G071	475	3:0£ 10 <sup>i 8</sup>	2.0	500
G047	500	3:0£ 10 <sup>i 8</sup>	2.0	500
G041	500	1:5£ 10 <sup>i 8</sup>	1.5	400
G044	500	3:0£ 10 <sup>i 8</sup>	1.5	450
G136	475	3:0£ 10 <sup>i 8</sup>	1.5	450

### Morphology



- $T_S = 400^{\circ}C$ : Coalescence
- T<sub>s</sub>=500°C: Baseball-bate shape



Diameters: 80-150 nm (30 nm) Heights: 200-600 nm (1500 nm)

Growth conditions strongly affect NCs morphology.



#### $T_S = 500^{\circ}C$ : Homogeneous NCs



#### Raman scattering spectroscopy Backscattering Z(X, -)-ZAllowed modes: $A_1(LO) - E_2^h$ $E_2^h$ mode: narrow peak 1,2-500°C Strain free 475⁰C NCs Intensity (arb. units) -6'0 $(^{2}_{XX} < 0.1\%)$ (x2 $A_1(L\Phi)$ PLP<sup>-</sup> E\_(TO A<sub>1</sub>(TO) Forbidden modes 7 www 0,0 480 500 580 420 600 440 460 Raman shift (cm<sup>-1</sup>) Scattering at lateral walls. Plasmon - LO phonon coupled mode (PLP-)

### Raman scattering spectroscopy



#### Photoluminescence: growth conditions





### Photoluminescence excitation (PLE)



- 10K.
- Excitation: Halogen lamp + monochromator.
- Detection: N<sub>2</sub>-cooled InAs Photodiode.
- Spectral resolution: <1.5 meV

### PLE: characteristics

Line-shape similar to bulk material.

Featureless – High electron concentration



### Accumulation layer: growth conditions

PLE is different for each sample.



Energy and FWHM of the PL peak increase as  $E_{abs}$  increase.

PL peak energy does not follow  $E_{abs}$  variation.







### Conclusions

• Optical properties and morphology of the nanocolumns are strongly affected by the growth conditions.

- There is electron accumulation at the non-polar surfaces of InN.
- Photoluminescence in InN nanocolumns comes from degenerated electrons recombining with localized holes.

• Differences in the photoluminescence are attributed to different volume and surface charge for each sample. Electron accumulation at non-polar surfaces is not intrinsic.

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